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INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(51) International Patent Classification 6 : A47L 9/14	A1	(11) International Publication Number: WO 96/32878 (43) International Publication Date: 24 October 1996 (24.10.96)
(21) International Application Number: PCT/US96/04146 (22) International Filing Date: 27 March 1996 (27.03.96) (30) Priority Data: 08/425,292 20 April 1995 (20.04.95) US 08/533,001 25 September 1995 (25.09.95) US (71) Applicant: MINNESOTA MINING AND MANUFACTURING COMPANY [US/US]; 3M Center, P.O. Box 33427, Saint Paul, MN 55133-3427 (US). (72) Inventors: ZHANG, Zhiquan; P.O. Box 33427, Saint Paul, MN 55133-3427 (US). WINTERS, John, C.; P.O. Box 33427, Saint Paul, MN 55133-3427 (US). (74) Agents: BOND, William, J. et al.; Minnesota Mining and Manufacturing Company, Office of Intellectual Property Counsel, P.O. Box 33427, Saint Paul, MN 55133-3427 (US).		(81) Designated States: AL, AM, AT, AU, AZ, BB, BG, BR, BY, CA, CH, CN, CZ, DE, DK, EE, ES, FI, GB, GE, HU, IS, JP, KE, KG, KP, KR, KZ, LK, LR, LS, LT, LU, LV, MD, MG, MK, MN, MW, MX, NO, NZ, PL, PT, RO, RU, SD, SE, SG, SI, SK, TJ, TM, TR, TT, UA, UG, UZ, VN, ARIPO patent (KE, LS, MW, SD, SZ, UG), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, CH, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, ML, MR, NE, SN, TD, TG). Published <i>With international search report.</i>
(54) Title: SHOCK RESISTANT HIGH EFFICIENCY VACUUM CLEANER FILTER BAG		
(57) Abstract There is provided a vacuum cleaner bag (20) with high fine particle removal efficiency under normal and shock loading conditions, shock loading comprising a short term challenge with high particle concentrations (e.g., when a vacuum is used to pick up a pile of debris). The bag also exhibits high loading capacity without significant loss in pressure drop. The bag comprises an outer support layer (2), a fibrous layer (13) that is charged to create electrets, and an inner diffusion layer (14) that is substantially unbonded to the filter layer, except at necessary bag seams (25) required for assembly of the filter bag.		